Electrochromic behavior of WO₃ thin films prepared by GLAD

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ABSTRACT
WO₃ thin films fabricated by glancing angle deposition (GLAD) are proposed as excellent electrochromic coatings with favorable ion diffusion. A ~ 500-nm film prepared by GLAD had a relatively large transmittance modulation. The crystallization structure, surface morphology, chemical state, optical and electrochromic properties of WO₃ thin films were systematically characterized upon annealing treatment. Compared with annealed WO₃ porous nanostructured films, the amorphous as-deposited films exhibited a high coloration efficiency and stable reversibility. Furthermore, the GLAD WO₃ films exhibit the tunable angular selectivity under illumination with p-polarized light because of the birefringence, which could extend the application range of nanostructured films in the electrochromic field.

1. Introduction
Electrochromism is a phenomenon whereby the color of some transition-metal oxide materials can be changed reversibly by applying an electric field. Tungsten trioxide (WO₃) electrochromic materials have excellent optical modulation and cycle stability with good application prospects in energy conservation and artificial intelligence, such as smart windows, displays, anti-dazzle mirrors, and effective disguises [1–4]. Based on the electrochemical double injection/extraction of M⁺ ions (small size cations, such as H⁺, Li⁺, Na⁺, and K⁺) and electrons, amorphous and crystalline WO₃ can be switched reversibly between the colored and bleached states by alternately applying a weak negative and positive voltage [5]. In comparison, nanostructured WO₃ films exhibit a larger surface area for ion diffusion and electron injection/extraction, along with a larger optical contrast ratio, faster switching speed, and higher coloration efficiency [6,7]. Many researchers have investigated the electrochromic properties of nanostructured WO₃ thin films.

Glancing angle deposition (GLAD), which involves manipulating the deposition angle and substrate rotation during the physical vapor deposition process, is a versatile nanofabrication technique based on the self-shadowing effect [8]. Nanostructures prepared by GLAD have the distinctive features of morphology sculpture, hetero-nanostructure design, and composition tenability by manipulating the nanoscale morphology and porosity, which also affect the film birefringence and dichroism [9,10]. Recently, considerable research has focused on nanostructured WO₃ electrochromic films fabricated by GLAD, and improvements in electrochromic performances have been discussed [11–15]. Beydaghyan et al. [14] found that the colored state of GLAD films exhibited an absorption-based coloration in the lower wavelengths as well as an increased reflection in the infrared region. Xiao et al. [12] successfully fabricated highly porous, oriented WO₃ nanocolumns on a flexible substrate by a facile electron-beam evaporation combined with the GLAD technique. Additionally, the electrochromic properties of WO₃ thin films have been studied under different annealing conditions [16–20]. Ng et al. [16] reported that WO₃ nanoplates annealed at 200°C exhibited a high coloration efficiency, large optical modulation, and good electrochromic cycling stability, as well as short ions insertion and extraction cycles. Sallard et al. [17] demonstrated that sufficient crystallinity of WO₃ films was needed to ensure the cycling stability under realistic environmental conditions. Nevertheless, for nanostructured WO₃ films prepared by GLAD, the influence of annealing on the electrochromic properties are not well-explored. Our previous studies show that annealing treatment causes surface morphology degradation on GLAD films [21–23]. Therefore, the evolutions of the morphological, structural, and optical performances of WO₃ GLAD films under different annealing treatment should be investigated as well. Particularly, the electrochromic property...
of WO₃ GLAD thin films combining with the birefringence is worth pursuing further.

In this study, we present detailed research on WO₃-based thin films fabricated by GLAD. Firstly, the relatively optimal film thickness has been selected by comparing the film optical modulation. Then, morphologies, structures and optical properties are characterized. And the impacts of annealing temperatures on electrochromic properties of WO₃ nanostructured thin films are systematically investigated. Our results extend the knowledge into the tunable angular selective transmittance of tilted nanorods WO₃ films.

2. Experiments

2.1. Synthesis of nanostructured WO₃ films

Fluorine-doped tin oxide (FTO) glass substrates were ultrasonically cleaned in acetone and ethanol for 30 min. WO₃ films were deposited in an electron-beam evaporation chamber with GLAD manipulator [24]. The base pressure was <1.5 × 10⁻⁵ Torr, and the distance from the center of the substrates to the WO₃ (purity 99.9%) source material was maintained at 27 cm. With a flow rate of 200 sccm, WO₃ thin films were deposited in a 2-mTorr oxygen atmosphere. The deposition angle between the incident flux and the normal of substrate was set as 70° without rotation and heating. During the coating process, the deposition rate was maintained at approximately 0.25 nm/s via quartz crystal oscillator monitoring. Then, 900-, 500-, and 270-nm films were fabricated. The films were annealed at different temperatures (100, 200, 300, 350, and 400 °C) in air for 2 h at a heating rate of 100 °C·h⁻¹ to consider the effect of the annealing temperature.

2.2. Characterizations

The morphologies of the WO₃ thin films were characterized by scanning electron microscopy (SEM, Hitachi S-4700). The crystallographic structures of the WO₃ films were characterized by X-ray diffraction (XRD, Empyrean, PANalytical), adopting a Rigaku D/MAX-2550 with Cu Kα (λ = 1.5408 Å). Raman spectra were measured in Renishaw Invia Raman Spectrometer under a 532.14-nm laser. X-ray photoelectron spectroscopy (XPS) was performed using an ESCALAB 250 (Thermo Scientific) with an Al Kα emission line at 1486.6 eV and an analyzer pass energy of 10 eV, and the spectra were analyzed using the commercial software Casa XPS. All binding energies were referenced to the C1s peak at 284.6 eV of the surface adventitious carbon to correct the shift caused by the charge effect.

2.3. Electrochemical and electrochromic evaluation

The electrochromic performances were obtained using a standard three-electrode, one-compartment electrochemical cell. The WO₃ film (Ø30 mm), a platinum sheet (35 mm × 35 mm), and Ag/AgCl (3.5 mol·L⁻¹ KCl) were utilized as the working, counter, and reference electrodes, respectively. The electrolyte solution was hydrochloric acid (1 mol·L⁻¹). By applying voltages between −0.5 V and +0.5 V, chronoamperometry (CA) and cyclic voltammetry (CV) were performed using an electrochemical workstation (UN-O-16027, Zahhner Zennium). The transmittance spectra were measured in the spectral region between 300 and 1000 nm using the spectrophotometer (Lambda 900). The p-polarized light transmittance of ±45° symmetry incidence was measured in the spectral region between 300 and 2000 nm.

3. Results and discussion

3.1. Thickness selection

As shown in Fig. 1, the thicker film of 900 nm exhibits a transmittance that is lower than expected because of the higher absorption. We chose films with thicknesses of 500 and 270 nm as subjects to study the transmittance modulation.

As a type of electrochromic material, the WO₃ film is transformed from the bleached state into the colored state by applying a negative voltage, which is represented as WO₃ + xM⁺ + xe⁻ ↔ MₓWO₃ [5], causing crystal structure variation. Then, electrons and cations are expelled out of intracell by applying a positive voltage, and the film changes to a transparent state [25]. Therefore, WO₃ thin films were subjected to a −0.5-V (or +0.5-V) voltage for 10 s to obtain the colored (or bleached) state, and transmittance spectra were measured in the spectral region between 300 and 1000 nm using the spectrophotometer.

As shown in Fig. 2, the transmittance shifts of the 500- and 270-nm films are 42.3% and 29.2% at 633 nm, respectively. However, the 270-nm film is too thin to store more cations and electrons; thus, the colored state of the 270-nm film exhibits a higher transmittance than that of the 500-nm film. Consequently, we shifted our focus to 500 nm as a relatively desirable thickness. According to Fig. 2, the 500-nm WO₃ film, the transmittance of the colored state decreases with an increasingly negative applied voltage, indicating that a stronger negative voltage yields a larger charge capacity.

3.2. Structural analysis

WO₃ electrochromism is based on the electrochemical double insertion and extraction of electrons and cations, along with the phase transformation. WO₃ film crystallization affects the electrochromic performance as well. Although the structure and morphology of the WO₃ thin film has been considered to be the key roles in determining electrochromic properties [7,26], the influence of the annealing temperature for WO₃ thin films prepared by GLAD is still few reported.

XRD patterns for annealed WO₃ films are shown in Fig. 3. Obviously, no characteristic diffraction peaks of the as-grown sample are observed, which indicates that the as-grown film is in a fully amorphous state. Furthermore, the diffraction peaks of both the 350 °C-annealed sample and the 400 °C-annealed sample are sharp and intense, indicating their highly crystalline nature. No impurity peaks are observed, confirming the high purity of the two samples.

![Fig. 1. Transmittance of WO₃ films with thicknesses of 900, 500, and 270 nm.](image-url)
Therefore, the amorphous WO₃ film crystallizes around 350 °C, and the crystalline phases of both the 350 and 400 °C-annealed samples correspond to triclinic WO₃ (ICSD 80055, P₁ space group) [27]. Fig. 4 shows the Raman spectra of WO₃ films annealed at different temperatures, which generally agree with the XRD patterns. Evidently, the WO₃ films transform from the amorphous state into the polycrystalline state when the annealing temperature increases to 350 °C. However, the Raman spectrum of the 300 °C-annealed sample exhibits weak peaks at 270, 328, 715, and 807 cm⁻¹. The characteristic positions of these peaks are in accordance with the fundamental mode of vibrations corresponding to the triclinic phase of WO₃ [28]. Apparently, the amorphous WO₃ film starts crystallizing at 300 °C.

3.3. Evolution of morphology

The top-view and cross-sectional SEM images of the WO₃ thin films in Figs. 5 and 6 show the surface morphologies and microstructures, respectively. The high-magnification SEM images shown in Fig. 6 indicate that the GLAD films consist of tilted and ordered WO₃ columns prepared at a deposition angle 70°. The unique microstructure of the WO₃ film can effectively increase the electrode/electrolyte contact areas and facilitate the electrons transfer and ions migration in the electrochemical reaction [29]. Along with the temperature increasing, the surface morphologies of the films change significantly. For example, consider the micro-pore size of the films in Fig. 5: the columns begin to agglomerate after the annealing treatment. Carefully examining the morphologies of films annealed at 100, 200, and 300 °C reveals that the columns are more tightly packed than those of the as-deposited sample, and the porosity of the samples decreases as the annealing temperature increases to 300 °C. However, the columnar structures of the films are separated by larger void regions with annealing temperature above 350 °C, as shown in Fig. 5(e) and (f). The porosity increase of the 350 °C-annealed sample is due to the higher-temperature treatment causing the columns to agglomerate more tightly and form larger void regions. Besides, the columns and the small grains on the columns clearly agglomerate, as shown in Fig. 5(f) and 6(f), indicating that the density of the sample increases after annealing at 400 °C. Messier et al. [30] demonstrated that these columns of GLAD films are composed of smaller micro-column structures. Therefore, the morphology of GLAD films can be seriously influenced by the annealing treatment. The density of the WO₃ film varies as the annealing temperature increases because of the agglomeration of the columns and the crystallization of the material, which agrees with the results of our previous
study concerning the morphology evolution of films prepared by GLAD under annealing treatment [22,23].

3.4. Chemical state analysis

XPS was used to characterize the surface composition and chemical states of WO₃. The W 4f core-level spectrum of the 400 ºC-annealed WO₃ film exhibits two contributions: 4f₅/₂ and 4f₇/₂, located at 37.5 and 35.4 eV, respectively, as shown in Fig. 7 (a). This clearly indicates the presence of the six-valent tungsten (W⁶⁺) oxidation state [31,32]. The W4f core-level peaks of WO₃ shift slightly (by approximately 0.4 eV) to lower binding energy side after the 400 ºC annealing. Additionally, the W4f core-level peaks become sharper and more distinguishable above the annealing temperature of 350 ºC. The O1s spectrum shown in Fig. 7(b) exhibits red shift as well. The shift is evidence of the chemical valence state transformation. The shift amounts of W4f and O1s depend on the oxygen-sufficient value, highlighting the oxygen-deficient state in the film annealed above 350 ºC. Thus, the high-temperature annealing can partially reduce WO₃ but is too weak to significantly change the chemical valence state.

3.5. Electrochromic performances

The transmission spectra of WO₃ films annealed at different temperatures were measured using the UV–vis spectrophotometer in the spectral region between 300 and 1000 nm, as shown in Fig. 8. The results indicate that the as-grown WO₃ film has a relatively large optical modulation (42.2%, 633 nm). As the annealing temperature increases, the bleached-state transmittance of the annealed samples decreases gradually. The optical modulation decreases rapidly from 42.2% to 7.2% after the 400 ºC annealing.
The coloration/bleaching switching characteristics were recorded at 633 nm, as shown in Fig. 9. A small sudden bounce of the optical contrasts (%ΔT) appears at 350 °C, which is due to the slightly high bleached-state transmittance of the 350 °C-annealed sample. To explain this bounce, we consider the evolution of the porosity, which decreased initially and then increased as the annealing temperature increased, as shown in Fig. 5. The porosity of the samples after 100, 200, and 300 °C annealing gradually decreased because of the agglomeration of the columns. Consequently, the transmittance of the samples after 100, 200, and 300 °C annealing also decreased gradually, along with the film densities increasing. However, the void regions of film after 350 °C annealing is larger than that of the 200 and 300 °C-annealed samples; thus, the 350 °C-annealed sample shows a higher transmittance in the bleached state. Therefore, the small sudden bounce of the optical contrasts indicates good agreement between the porosity and transmissivity of the annealed samples. Besides, the optical modulation degraded significantly after 400 °C annealing. The colored-state transmittance and bleached-state transmittance of the 400 °C-annealed sample apparently increased and decreased, respectively, owing to the high-temperature annealing and WO₃ crystallization. High-temperature annealing changes the crystalline host lattice and increases the potential energy barriers, causing difficulty insert or extract ions sequentially. Consequently, the optical modulation of films under treatment at different temperatures is an outcome of the combined effects of the film porosity and crystallinity. The results demonstrate that the amorphous WO₃ film prepared by GLAD exhibited superior electrochromic performance to the crystalline WO₃ film [33,34].

Among the characteristic parameters determining the electrochromic properties, the cycling stability is regarded as one of the most important factors [35,36]. The CV curves in Fig. 10 show the cycling stability and degree of difficulty for ions transfer into films after 100 cycles. Obviously, the as-grown film has an optimal
charge capacity and better cycling stability than the annealed film. A significantly deterioration of the CV curve is observed as the annealing temperature increases, indicating that the annealing treatment reduces the charge capacity and redox reversibility. As the annealing temperature increases, the ordered lattice, the stable structure, and the increasing potential barriers of the ions intercalation can inhibit ion insertion and reduce the cycling stability [33]. As a result, the as-grown GLAD film has an optimal electrochromic property with a satisfactory cycling stability and large optical modulation, as the amorphous structure with defects is beneficial for ion insertion and extraction.

A Raman spectroscopic investigation of the colored and bleach states of the 350 °C-annealed sample was conducted to gain further insight into the structural changes. Raman spectroscopy has been proven as a powerful local structural probe for WO3, as shown in Fig. 11. Specifically, all the peaks of the 350 °C-annealed film broaden significantly and exhibit a weak shift to a lower frequency (redshift) after the electrochromic reaction, and the peaks at the low frequency increase in intensity. All the data shown in Fig. 11 suggest that the stress fluctuation and phase transformation occur during the electrochromic reaction in the crystalline WO3. The mechanism of electrochromism has long been controversial. The variation results of the Raman peaks indicate that internal stress fluctuation rather than phase transformation may dominate during the 350 °C-annealed film electrochromic reaction. Therefore, the specific mechanism remains to be further explored.

3.6. Angular selectivity

Major studies have focused on nanoscale materials for improving the electrochromic performance. However, the tilted nanocolumns thin film prepared by GLAD is characterized by birefringent characters [37–39]. Few studies have reported the unique optical nature of the birefringence for WO3 GLAD thin films, which can result in angular selective transmittance [40,41]. Therefore, we investigated the angular selective transmittance of the as-grown
GLAD WO₃ films in the electrochromic field. The detailed propagating theory, parameters, and regulation regarding the symmetry incidence can be found in the literature [21,39].

As shown in Fig. 12, under illumination with p-polarized light at ±45° symmetry incidence (in the case of the incident plane coinciding with the vapor incidence plane), the spectrum curves of the colored state are not exactly consistent with that of the bleached state. From Fig. 12(a), the angular selectivity of the colored states exhibits a larger modulation than that of the bleached states, which is attributed to the absorption increase of the colored states. The optical contrasts (%ΔT) of as-grown GLAD WO₃ films at +45° and −45° incidence in the vis–IR region are shown in Fig. 12(b). The difference of the transmittance modulation contrast for the p-polarized light between the +45° and −45° incidence can be up to 11%. Apparently, the WO₃ thin film shows a relatively large optical modulation in the vis and near-IR region (1000–1400 nm), but the optical modulation in the IR region (>1600 nm) is small. Nonetheless, the doping modification is a feasible proposal for improving the transmittance modulation performance in the IR region. The optical transmittance contrasts of the colored states under the p-polarized light with ±45° incidence obtained by applying different voltages are shown in Fig. 13. In the 400–1000-nm region, the transmittance decreases significantly at the voltage of −1 V owing to the more H⁺-ion insertion. As indicated by the optical modulation in Fig. 13, the angular selectivity of the GLAD WO₃ films with the unique microstructure could be adjusted by applying different voltages. Therefore, the special performance of the tilted columnar electrochromic films provides new application features and development potential.

4. Conclusion

WO₃ thin films were fabricated by glancing angle deposition technique (GLAD) and annealed at different temperatures. The WO₃ films begin to crystallize at around 300 °C. Comparing with the annealed films, the as-grown GLAD WO₃ film exhibits relatively optimum electrochromic properties, along with a satisfactory cycling stability and large optical modulation (42.2%, 633 nm), because the loose structure facilitated fast ion diffusion and rapid color alteration. Furthermore, a noteworthy feature of tilted columnar structured films is that under illumination with p-polarized light, the transmittance modulation contrast between the +45° and −45° incidence can be up to 11%. The angular selectivity of the colored and bleached states of GLAD WO₃ films illuminated with p-polarized light can be tuned by applying different voltages, which provides new application features and development potential.

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